



# FINAL CALL FOR PAPERS

ABSTRACTS DUE DEC 19, 2024

# 2025 International **Image Sensor Workshop**

Awaji Yumebutai Int. Conf. Center, Hyōgo, Japan June 2 - 5, 2025

### General Workshop Co-Chairs:

Yusuke Oike \*

Sony, Japan

Shoji Kawahito

Shizuoka University and SUiCTE, Japan

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#### Jan Bogaerts

Gpixel, Belgium

The 2025 International Image Sensor Workshop (IISW) provides a biennial opportunity to present innovative work in the area of solid-state image sensors and share new results with the image sensor community. The event is intended for image sensor technologists; in order to encourage attendee interaction and a shared experience, attendance is limited, with strong acceptance preference given to workshop presenters. As is the tradition, the 2025 workshop will emphasize an open exchange of information among participants in an informal, secluded setting beside the Awaji Island in Hyōgo, Japan.

The scope of the workshop includes all aspects of electronic image sensor design and development. In addition to regular oral and poster papers, the workshop will include invited talks and announcement of International Image Sensors Society (IISS) Award winners.

Papers on the following topics are solicited:

### **Image Sensor Design and Performance**

CMOS imagers, CCD imagers, SPAD sensors New and disruptive architectures Global shutter image sensors Low noise readout circuitry, ADC designs Single photon sensitivity sensors High frame rate image sensors High dynamic range sensors Low voltage and low power imagers High image quality; Low noise; High sensitivity Improved color reproduction Non-standard color patterns with special digital processing Imaging system-on-a-chip, on-chip image processing Event-based image sensors

#### **Pixels and Image Sensor Device Physics**

New devices and pixel structures Advanced materials Ultra miniaturized pixels development, testing, and characterization New device physics and phenomena Electron multiplication pixels and imagers Techniques for increasing QE, well capacity, reducing crosstalk, and improving angular response Frontside illuminated, backside illuminated, and stacked pixels and pixel arrays

Pixel simulation: optical and electrical simulation, 2D and

3D, CAD for design and simulation, improved models

### **Application Specific Imagers**

Image sensors and pixels for range sensing: LIDAR, TOF, RGBZ, structured light, stereo imaging, etc. Image sensors with enhanced spectral sensitivity (NIR, UV, IR) Sensors for DSC, DSLR, mobile, digital video cameras and mirror-less cameras Array imagers and sensors for multi-aperture imaging, computational imaging, and machine learning Sensors for medical applications, microbiology, genome sequencing High energy photon and particle sensors (X-ray, radiation)

Line arrays, TDI, large format imagers Multi and hyperspectral imagers

Polarization sensitive imagers

#### **Image Sensor Manufacturing and Testing**

New manufacturing techniques Wafer-on-wafer and chip-on-wafer stacking technologies Backside thinning New characterization methods Packaging and testing: reliability, yield, cost Defects, noises, and leakage currents Radiation damage and radiation hard imagers

#### **On-chip Optics and Color Filters**

Advanced optical path, color filters, microlens, light guides Nanotechnologies for Imaging Wafer level cameras

#### Johannes Solhusvik \*

Sony, Norway

#### Jun Ogi

Sony, Japan

# Junichi Nakamura \*\*

Brillnics, Japan

#### **Kazuhiro Morimoto**

Canon, Japan

#### Manylun Ha

DB Hitek, South Korea

#### Michael Guidash

R.M. Guidash Consulting, USA

# Michelle Yibing Wang \*

Samsung, USA

#### **Neale Dutton**

ST Microelectronics, UK

#### Pierre Magnan

ISAE, France

#### Preethi Padmanabhan

Pointcloud, Switzerland

#### Robert Henderson \*

University of Edinburgh, UK

#### Shoji Kawahito

Shizuoka University and SUICTE, Japan

### Shouleh Nikzad \*

Jet Propulsion Lab, USA

#### **Vladimir Korobov**

ON Semiconductor, USA

# Vladimir Koifman \*

Analog Value, Israel

#### \*\* IISS President

\* IISS Director

# IISS Governance Advisory Committee:

#### **Eric Fossum**

Thayer School of Engineering at Dartmouth, USA

#### Nobukazu Teranishi

Shizuoka University, Japan

#### **Albert Theuwissen**

Harvest Imaging, Belgium

#### **Submission of abstracts:**

An abstract should consist of a single page of maximum 500-words text with up to two pages of illustrations (3 pages maximum), and include authors' name(s), affiliation, mailing address, telephone number, and e-mail address.

The deadline for abstract submission is **11:59pm**, **Thursday Dec 19, 2024 (GMT)**. To submit an abstract, please go to: <a href="https://cmt3.research.microsoft.com/IISW2025">https://cmt3.research.microsoft.com/IISW2025</a> Above website is now open for submission.

The first time you visit the paper submission site, you'll need to click on "Create Account". Once you create and verify your account with your email address, you will be able to submit abstracts by logging in and clicking "Create New Submission."

Please visit <a href="https://imagesensors.org/CFP2025">https://imagesensors.org/CFP2025</a> for complete instructions and any updates to the abstract and paper submission procedures.

Abstracts will be considered on the basis of originality and quality. High quality papers on work in progress are also welcome. Abstracts will be reviewed confidentially by the Technical Program Committee.

#### **Key Dates:**

Authors will be notified of the acceptance of their abstract latest by **Feb 10, 2025**. Final-form 4-page paper submission date is **Mar 22, 2025**. Presentation material submission date is **May 1, 2025**.

#### Location:

The IISW 2025 will be held at the International Conference Center on Awaji Island in Hyōgo Prefecture, Japan. This beautiful hotel is about 1 hour from Kansai International Airport. Limousine Buses chartered by IISW will pick up attendees at JR Shin-Kobe Station and JR Sannomiya Station.

# Registration, Workshop fee, and Hotel Reservation:

Pre-registration will be open on **Feb 17, 2025**. Priority seating will be given to presenters of accepted papers, resulting in a limited number of seats available for other attendees. Registration will generally be on a first-come, first-served basis. However, in line with the workshop's commitment to fostering diverse and lively discussions, the organizers reserve the right to adjust allocations to ensure a balanced representation of affiliations.

Registration details and hotel reservation information will be provided in conjunction with the opening of pre-registration.

Forthcoming announcements and additional information will be posted on the **2025 Workshop** page of the International Image Sensor Society website at:

https://www.imagesensors.org/